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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR			ATTORNEY DOCKET NO.	
8/811.742	03/06/97	ZHANG		H	0756	-1641
_		MM42/0803 % FERGUSON	コ	EXAMINER		
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2010 CORPORATE RIDGE SUITE 600 MCLEAN VA 22102			• • •	ART L	JNIT	PAPER NUMBER
			,	2823		29
			DATE MAILED: 08/03/99		03/99	

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

Office Action Summary

Application No. **08/811,742**

Applicant(s)

Zhang et al.

Examiner

Scott J. Hawranek

Group Art Unit 2823



7 - May 21 1000				
Responsive to communication(s) filed on May 21, 1999				
This action is FINAL .				
in accordance with the practice under Ex parte Quayle, 1				
A shortened statutory period for response to this action is session services of the second state of this communication. Failure application to become abandoned. (35 U.S.C. § 133). Extending CFR 1.136(a).	et to expire 3 month(s), or thirty days, whichever ure to respond within the period for response will cause the ensions of time may be obtained under the provisions of			
Disposition of Claims				
	is/are pending in the application.			
Of the above, claim(s) 49-66	is/are withdrawn from consideration.			
Claim(s)				
X Claim(s) 5-12, 16, 19, and 26-48				
Claim(s)	is/are objected to.			
☐ Claims	are subject to restriction or election requirement.			
Application Papers See the attached Notice of Draftsperson's Patent Drav				
The drawing(s) filed on is/are ob	ojected to by the Examiner.			
☐ The proposed drawing correction, filed on	is approved disapproved.			
\square The specification is objected to by the Examiner.				
\square The oath or declaration is objected to by the Examine	er.			
Priority under 35 U.S.C. § 119				
Acknowledgement is made of a claim for foreign prio				
X All ☐ Some* ☐ None of the CERTIFIED copie	es of the priority documents have been			
☐ received.	Number)			
received in Application No. (Series Code/Serialreceived in this national stage application from				
*Certified copies not received:				
Acknowledgement is made of a claim for domestic pr				
Attachment(s)				
☐ Notice of References Cited, PTO-892	AL ()			
☐ Information Disclosure Statement(s), PTO-1449, Paper	er No(s)			
Interview Summary, PTO-413Notice of Draftsperson's Patent Drawing Review, PTO-413	O-948			
Notice of Informal Patent Application, PTO-152				
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SEE OFFICE ACTION	ON THE FOLLOWING PAGES			

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DETAILED ACTION

Election/Restriction

1. Newly submitted claims 49-66 are directed to an invention that is independent or distinct from the invention originally claimed for the following reasons:

Species I: Claims 5-12,16,19 and 26-48 a method of forming a semiconductor device wherein forming a semiconductor film on the surface of a glass substrate.

Species II: Claims 49-66 relating to a method of forming a semiconductor device wherein forming a semiconductor film on an insulated surface of the substrate.

Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, Species II, claims 49-66 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

Claim Rejections - 35 USC § 103

2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

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3. Claims 5-12, 16, 19, 26, 27-48 are rejected under 35 U.S.C. 103(a) as being unpatentable over Oka (JP '915), in view of Lie et al. (US '826) and in further view of Kuznetsov (Inst. Phys. Conf.), as of record and in further view of Kumomi (US '661).

Kumomi (US '661) teaches MILC or catalyst enhanced areas crystal growth takes place parallel to the substrate (e.g. MILC). Therefore, it is held, absent evidence to the contrary, that crystal growth of Oka would occur by this mechanism. *See* In re Best, 195 USPQ 428 (CCPA 1977) and In re Fitzgerald, 205 USPQ 594 (CCPA 1980).

In addition, it should be noted that the specification contains no disclosure of either the critical nature of the claimed ranges of nickel concentration or any unexpected results arising therefrom over the prior art. Where patentability is said to be based upon particular chosen dimensions or upon another variable recited in a claim, the applicant must show that the chosen ranges are critical. In re Woodruff, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

Response to Arguments

4. Applicant has overcome previous 35 U.S.C. 112 rejections.

Applicant's arguments filed 5/21/99 have been fully considered but they are not persuasive.

In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on

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combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Applicant argues Oka does not disclose the purpose of leaving some areas amorphous. However, if applicant refers to rejection Liu is relied upon for that teaching in which some areas are left amorphous due to the nickel concentration or lack thereof and would have therefore understood the importance of the critical concentration of the catalyst (e.g. amount required to crystallize the a-si) in order to leave some areas amorphous as taught by Liu.

In addition, applicant argues that Kuznetsov does not teach the lateral crystal growth since the catalyst is introduced to the whole surface (however nowhere is this stated by Kuznetsov explicitly) and the image shown are only cross-section views. However, MILC is still an inherent aspect of Oka as described above.

Conclusion

5. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period

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of this final action.

will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date

Any inquiry concerning this communication or earlier communications from the examiner 6. should be directed to Scott J. Hawranek whose telephone number is (703) 305-0070. The examiner can normally be reached on Monday thru Friday from 8:30 to 6:00 P.M. .

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M. Fahmy, can be reached on (703) 308-4918. The fax phone number for this Group is (703) 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-1778.

Scott J. Hawranek Art Unit: 2823 June 28, 1999

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